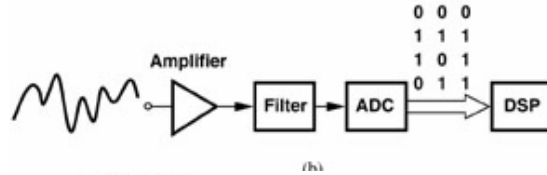
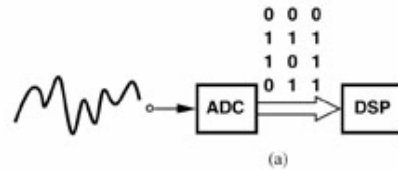


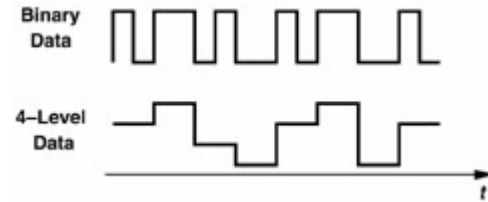
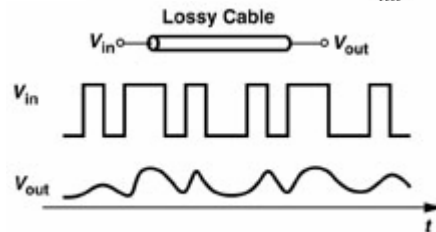
ΕΙΣΑΓΩΓΗ ΣΤΗΝ ΑΝΑΛΟΓΙΚΗ ΣΧΕΔΙΑΣΗ

Γιατί Αναλογικά;

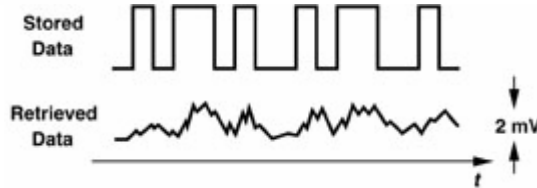
Επεξεργασία Φυσικών σημάτων.



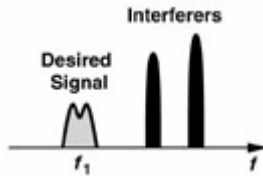
Ψηφιακές επικοινωνίες.



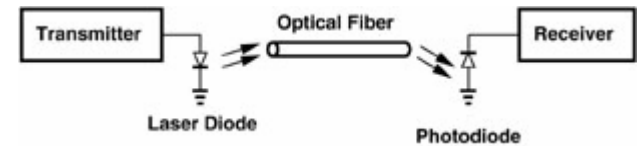
Ηλεκτρονικά Οδήγησης Δίσκων



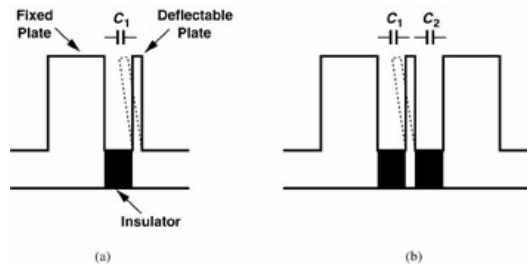
Ασύρματοι Δέκτες.



Οπτικοί Δέκτες.



Αισθητήρες.

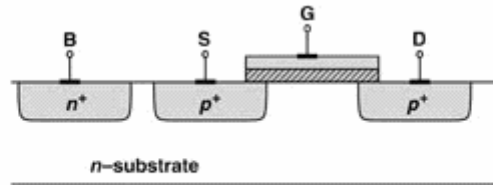
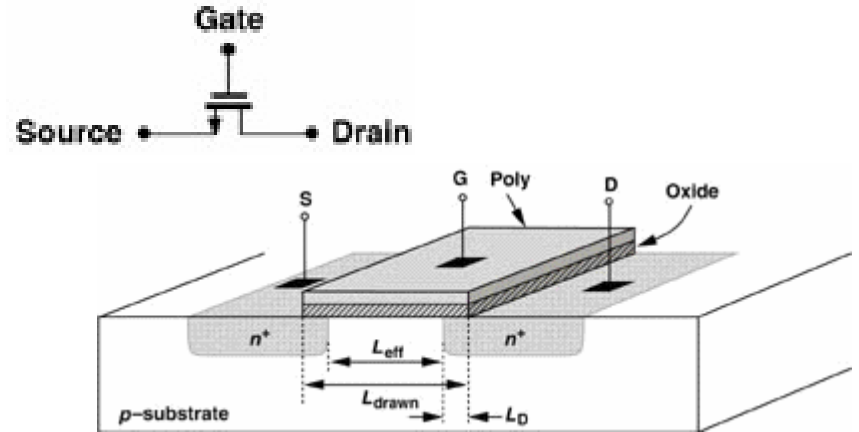
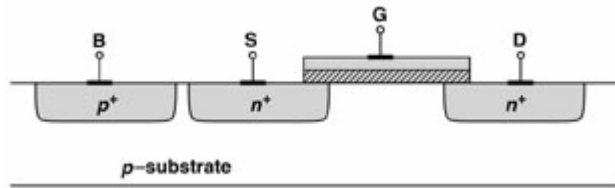


Μικροεπεξεργαστές και Μνήμες.

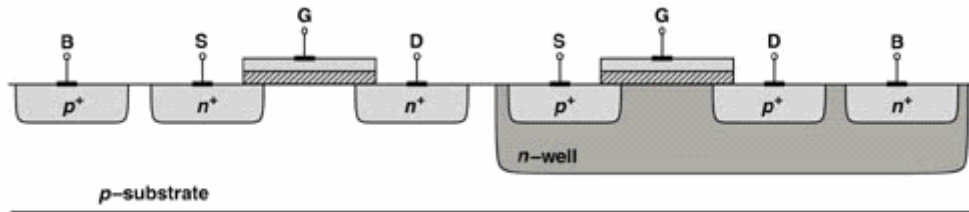
ΦΥΣΙΚΗ ΤΩΝ ΒΑΣΙΚΩΝ ΔΙΑΤΑΞΕΩΝ MOS

Το MOSFET σαν διακόπτης

Η δομή του MOSFET

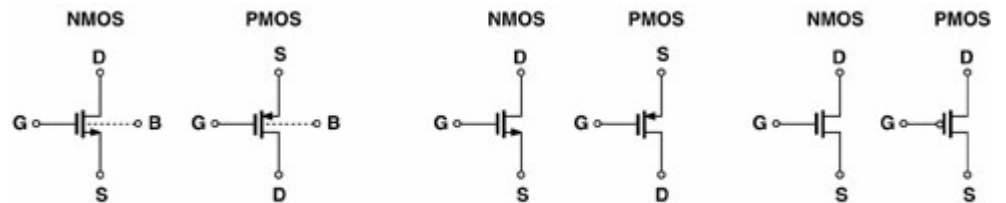


(a)



(b)

Συμβολισμοί των MOS



(a)

(b)

(c)

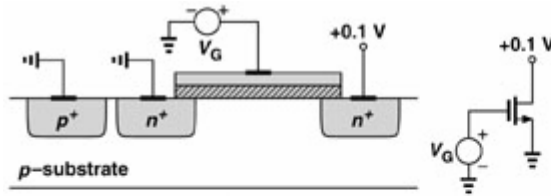
Χαρακτηριστικές I/V του MOS

Η τάση κατωφλίου:

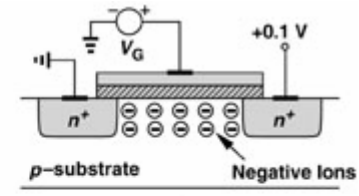
$$V_{TH} = \Phi_{MS} + 2\Phi_F + \frac{Q_{dep}}{C_{ox}}$$

$$\Phi_F = (kT/q) \ln(N_{sub}/n_i)$$

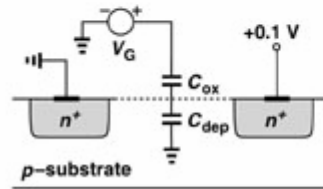
$$Q_{dep} = \sqrt{4q\epsilon_s |\Phi_F| N_{sub}}$$



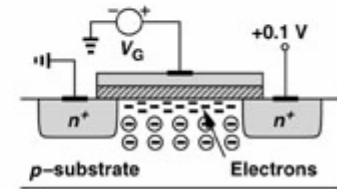
(a)



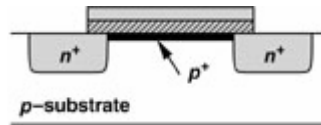
(b)



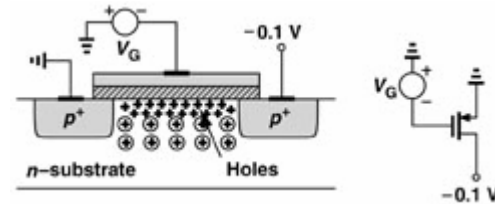
(c)



(d)

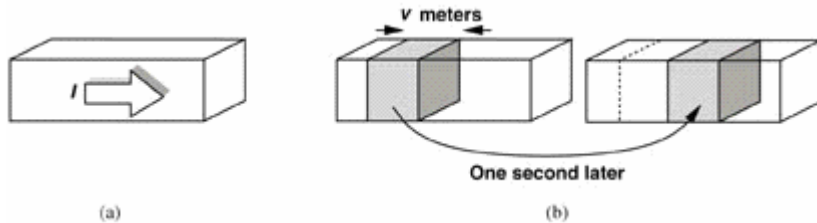


p-substrate



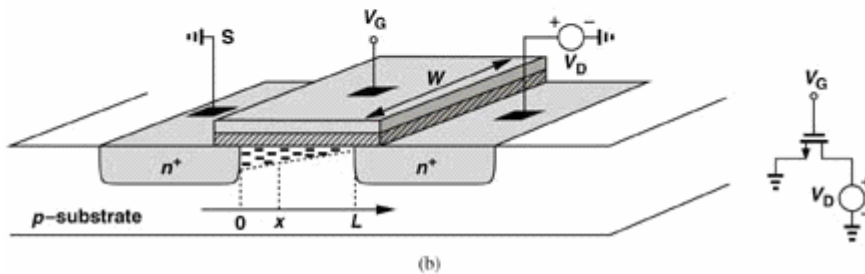
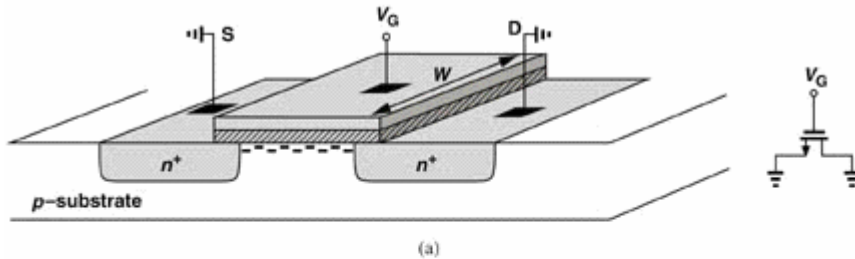
PMOS

Παραγωγή των χαρακτηριστικών I/V



$$I = Q_d \cdot v$$

$$Q_d = WC_{ox} (V_{GS} - V_{TH})$$



$$Q_d(x) = WC_{ox} [V_{GS} - V(x) - V_{TH}]$$

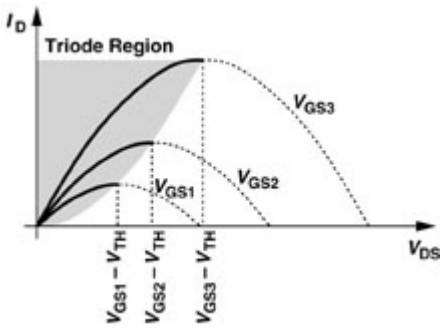
$$I_D = -WC_{ox} [V_{GS} - V(x) - V_{TH}] v$$

$$v = \mu E, E(x) = -\frac{dV(x)}{dx} \Rightarrow$$

$$I_D = WC_{ox} [V_{GS} - V(x) - V_{TH}] \mu_n \frac{dV(x)}{dx},$$

$$\int_{x=0}^L I_D dx = \int_{V=0}^{V_{DS}} WC_{ox} [V_{GS} - V(x) - V_{TH}] \mu_n dV(x),$$

$$I_D = \mu_n C_{ox} \frac{W}{L} [(V_{GS} - V_{TH}) V_{DS} - \frac{1}{2} V_{DS}^2].$$



$$\frac{\partial I_D}{\partial V_{DS}} = 0 \quad \text{για} \quad V_{DS} = V_{GS} - V_{TH}$$

$$I_D = \frac{1}{2} \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})^2$$

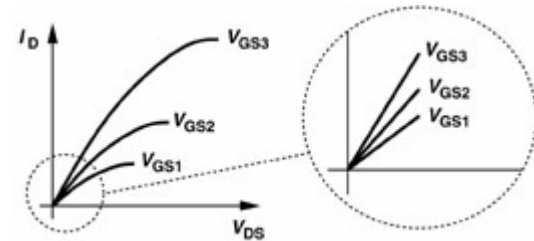
$V_{GS} - V_{TH}$ τάση υπεροδήγησης

Av

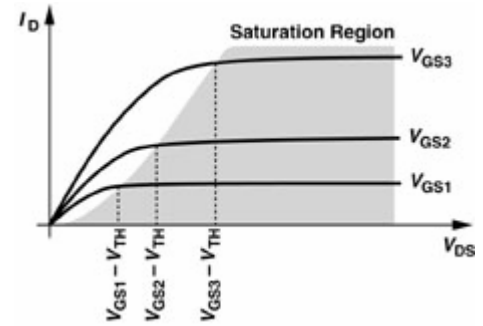
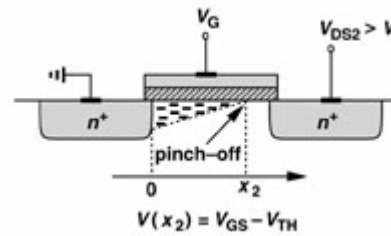
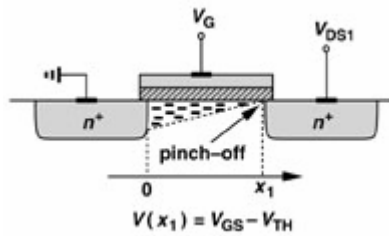
$$V_{DS} \ll 2(V_{GS} - V_{TH}),$$

$$I_D \approx \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH}) V_{DS},$$

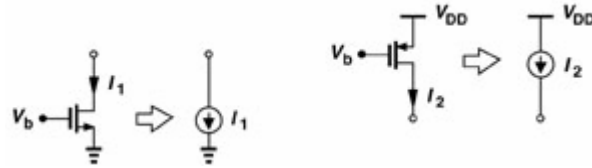
$$R_{on} = \frac{1}{\mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})}$$



$$V_{DS} > (V_{GS} - V_{TH})$$



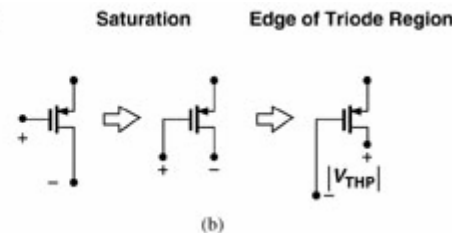
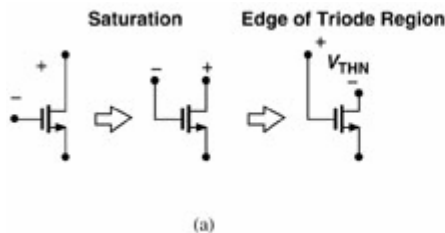
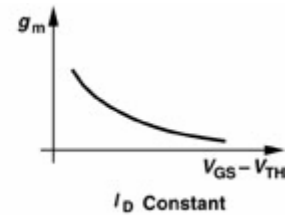
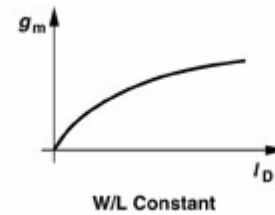
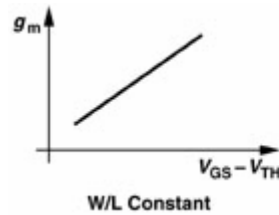
$$I_D = \frac{1}{2} \mu_n C_{ox} \frac{W}{L'} (V_{GS} - V_{TH})^2$$



PMOS
$$I_D = -\mu_p C_{ox} \frac{W}{L} [(V_{GS} - V_{TH}) V_{DS} - \frac{1}{2} V_{DS}^2]. \quad I_D = -\frac{1}{2} \mu_p C_{ox} \frac{W}{L'} (V_{GS} - V_{TH})^2$$

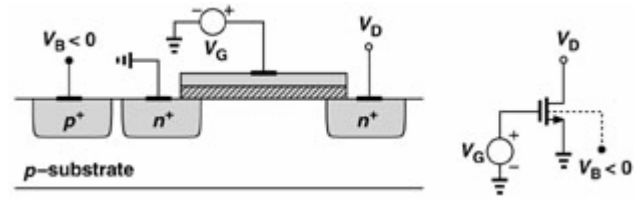
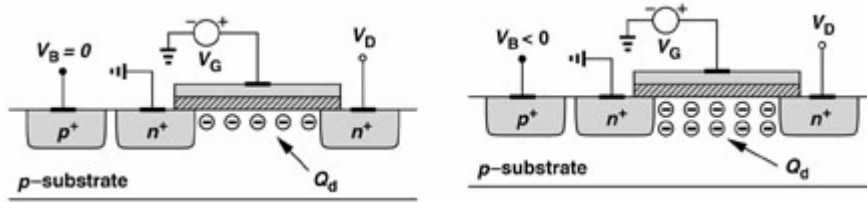
$$g_m = \left. \frac{\partial I_D}{\partial V_{GS}} \right|_{V_{DS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})$$

$$g_m = \sqrt{2 \mu_n C_{ox} \frac{W}{L} I_D} = \frac{2 I_D}{V_{GS} - V_{TH}}$$



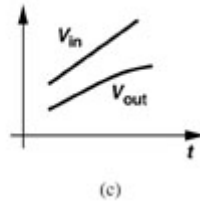
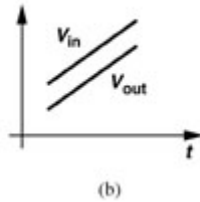
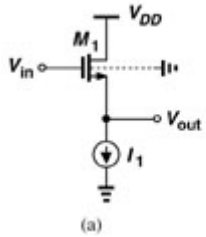
Φαινόμενα δευτέρας τάξεως

Το φαινόμενο Σώματος



$$V_{TH} = V_{TH0} + \gamma(\sqrt{2\Phi_F + V_{SB}} - \sqrt{2\Phi_F})$$

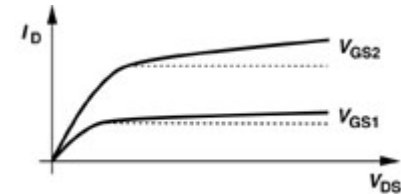
$$\gamma = \sqrt{2q\epsilon_s N_{sub} / C_{ox}}$$



$$I_1 = \frac{1}{2} \mu_n C_{ox} \frac{W}{L} (V_{in} - V_{out} - V_{TH})^2$$

Διαμόρφωση του Μήκους του Καναλιού

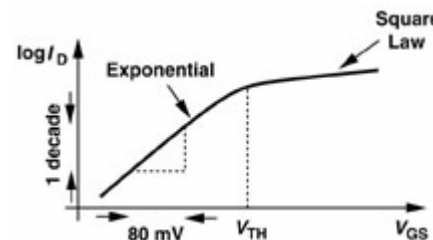
$$I_D \approx \frac{1}{2} \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})^2 (1 + \lambda V_{DS})$$



λ = συντελεστής διαμόρφωσης μήκους καναλιού $\sim 1/L$

Υποκατωφλική Αγωγιμότητα

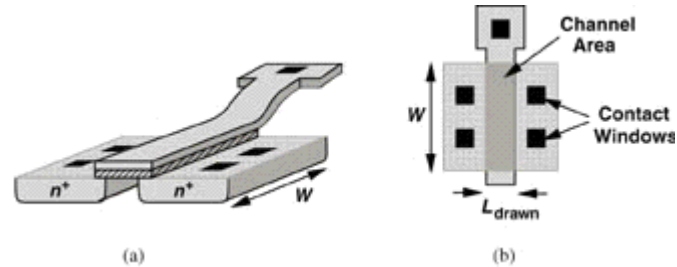
$$I_D = I_0 \exp \frac{V_{GS}}{\zeta V_T} \quad \zeta > 1$$



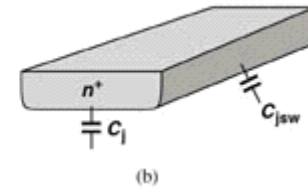
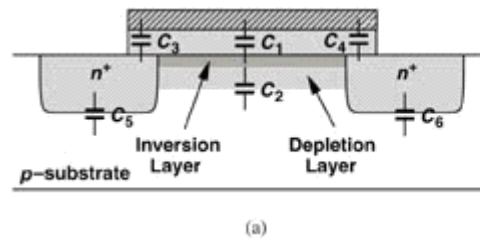
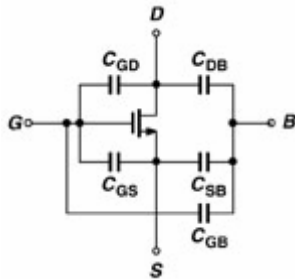
$$g_m = \frac{I_D}{\zeta V_T}$$

Μοντέλα των διατάξεων MOS

Το ανάπτυγμα της διάταξης MOS

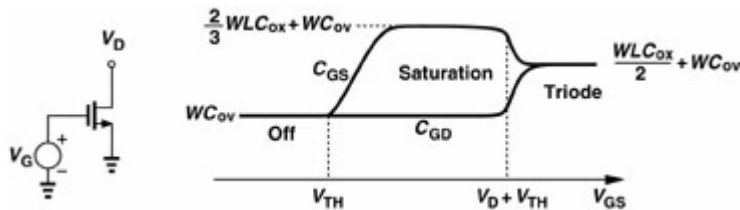


Οι χωρητικότητες της διάταξης MOS



$$C_1 = WLC_{ox} \quad C_2 = WL \sqrt{2q\epsilon_s N_{sub} / (2\Phi_F)} \quad C_3, C_4 (C_{ov})$$

$$C_j = C_{j0} / [1 + V_R (2\Phi_F)]^m \quad C_{jsw}$$



Το μοντέλο μικρού σήματος του MOS

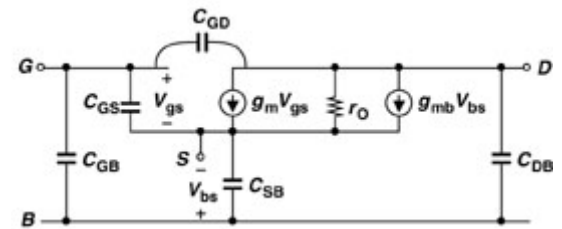
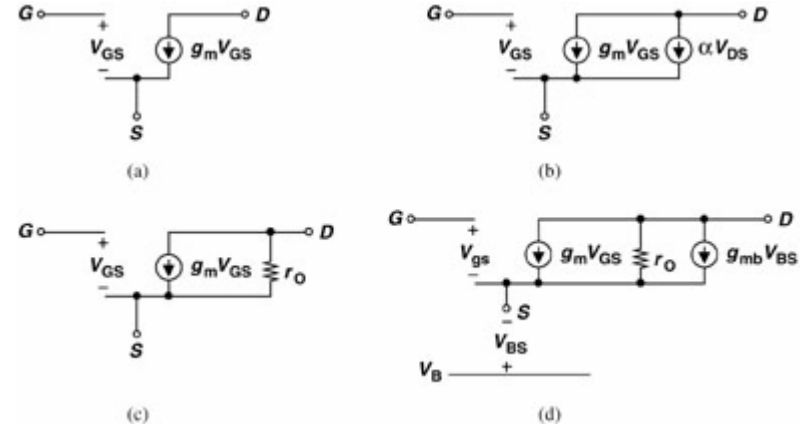
$$g_m = \left. \frac{\partial I_D}{\partial V_{GS}} \right|_{V_{DS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH}) = \sqrt{2\mu_n C_{ox} \frac{W}{L} I_D} = \frac{2I_D}{V_{GS} - V_{TH}}$$

$$r_D = \frac{\partial V_{DS}}{\partial I_D} = \frac{1}{\partial I_D / \partial V_{DS}} = \frac{1}{\frac{1}{2} \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH})^2 \lambda} \approx \frac{1}{\lambda I_D}$$

$$g_{mb} = \frac{\partial I_D}{\partial V_{BS}} = \mu_n C_{ox} \frac{W}{L} (V_{GS} - V_{TH}) \left(-\frac{\partial V_{TH}}{\partial V_{BS}} \right)$$

$$\frac{\partial V_{TH}}{\partial V_{BS}} = -\frac{\partial V_{TH}}{\partial V_{SB}} = -\frac{\gamma}{2} (2\Phi_F + V_{SB})^{-1/2}$$

$$g_{mb} = g_m \frac{\gamma}{2\sqrt{2\Phi_F + V_{SB}}} = \eta g_m$$



Οι παράμετροι του βασικού μοντέλου των διατάξεων MOS

Μοντέλο NMOS			
LEVEL=1	VTO=0.7	GAMMA=0.45	PHI=0.9
NSUB=9e+14	LD=0.08e-6	UO=350	LAMBDA=0.1
TOX=9e-9	PB=0.9	CJ=0.56e-3	CJSW=0.35e-11
MJ=0.6	MJSW=0.2	CGDO=0.4e-11	JS=1.0e-8
Μοντέλο PMOS			
LEVEL=1	VTO=-0.8	GAMMA=0.4	PHI=0.8
NSUB=5e+14	LD=0.09e-6	UO=100	LAMBDA=0.2
TOX=9e-9	PB=0.9	CJ=0.94e-3	CJSW=0.32e-11
MJ=0.5	MJSW=0.3	CGDO=0.3e-11	JS=0.5e-8